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APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
10/673,188 09/30/2003		09/30/2003	Hironobu Sai	033022-010	1256		
21839	7590	01/30/2006		EXA	EXAMINER		
		RSOLL PC	LE, T	LE, THAO X			
•		S, DOANE, SWECI	CER & MATHIS)	ARTIBUT	PAPER NUMBER		
POST OFFI	CE BOX 1	404	ART UNIT	PAPER NUMBER			
ALEXAND	RIA, VA	22313-1404	2814				

DATE MAILED: 01/30/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application N	0.	Applicant(s)	<i>U</i>				
	10/673,188		SAI ET AL.					
Office Action Summary	Examiner		Art Unit					
	Thao X. Le		2814					
The MAILING DATE of this communication ap	pears on the co	er sheet with the c	orrespondence ac	dress				
Period for Reply	VIC CET TO E	VDIDE 2 MONTU	S) EDOM					
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, he had a statutory within the statutory will apply and will expected, cause the application	owever, may a reply be tim minimum of thirty (30) days ire SIX (6) MONTHS from n to become ABANDONEI	ely filed s will be considered time the mailing date of this c O (35 U.S.C. § 133).					
Status								
1) Responsive to communication(s) filed on 22 E	December 2005.							
2a) ☐ This action is FINAL . 2b) ☒ This	s action is non-f	inal.						
	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
closed in accordance with the practice under it	Ex parte Quayle	e, 1935 C.D. 11, 45	3 O.G. 213.					
Disposition of Claims								
4) Claim(s) <u>1,3,4,10 and 11</u> is/are pending in the	application.							
4a) Of the above claim(s) 5-9 is/are withdrawn	n from considera	tion.						
5) Claim(s) is/are allowed.								
6)⊠ Claim(s) <u>1,3,4,10 and 11</u> is/are rejected.								
7) Claim(s) is/are objected to.	Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/o	or election requi	rement.						
Application Papers								
9) The specification is objected to by the Examine								
· • · · · · · · · · · · · · · · · · ·	10) The drawing(s) filed on is/are: a) accepted or b) dispected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correct								
11) ☐ The oath or declaration is objected to by the E	xaminer. Note t	ne attached Office	Action of form P	10-152.				
Priority under 35 U.S.C. § 119								
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documen 2. Certified copies of the priority documen 3. Copies of the certified copies of the priority documen * See the attached detailed Office action for a list 	nts have been re nts have been re ority documents au (PCT Rule 17	ceived. ceived in Application have been received 7.2(a)).	on No ed in this National	Stage				
Attachment(s)	4 1.	☐ Interview Summary	(PTO-413)					
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)		Paper No(s)/Mail Da	ite					
 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date 	,	Notice of Informal P Other:	atent Application (PT	O-152)				

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DETAILED ACTION

Claim Objections

1. Claim 3 is objected to because of the following informalities: Claims 3 depends on canceled claim 2. Appropriate correction is required.

Assuming claim 3 depends on claim 1.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 4. Claims 1-2, 3-4 and 10-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over US 5621750 to Iwano et al. in view of US 6716378 to Yang et al.

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Regarding claim 1, Iwano semiconductor light emitting device (LED) in fig. 5A comprising: a mesa section (convex portion) having at least sandwich structure of an n-type clad layer 104, column 14 line 51, an active layer 105, column 14 line 52, and a p-type clad layer 106, column 14 line 56, which are constituted by compound semiconductor layers formed on a substrate 102, column 14 line 45; and an inorganic insulating film formed 108, column 15 lines 5-15, to cover the mesa section excluding a contact region.

But, Iwano does not disclose the LED wherein the inorganic insulating film having a porous area defined by cylindrical vacancies, having vacancy rate of 50% or more while being oriented substantially in parallel with a surface of the substrate, and wherein the vacancies are arranged at periodic interval.

However, Yang discloses the inorganic insulating film having a porous area defined by cylindrical vacancies, having vacancy rate of 50% or more, col. 6 lines 32-35, while being oriented substantially in parallel with a surface of the substrate, col. 6 line 30, and wherein the vacancies are arranged at periodic interval, fig. 2A-5C. At the time the invention was made; it would have been obvious to one of ordinary skill in the art to use the inorganic layer teaching of Yang to replace the inorganic layer 108 in Iwano's device, because such insulating material would have produced a low dielectric constant and low-cost inorganic dielectric material as taught by Yang in column 2 lines 38-40.

The 'vacancy' is being interpreted as a 'porosity' or 'holes' structure.

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Regarding claim 3, Iwano does not disclose the semiconductor light emitting device according to claim 2, wherein the inorganic insulating film comprises a plurality of the porous structures, wherein the cylindrical are formed such that the cylindrical vacancies of adjacent porous structures are oriented in different directions.

However, Yang discloses a inorganic insulating film comprises a plurality of the porous structures, wherein the cylindrical are formed such that the cylindrical vacancies of adjacent porous structures are oriented in different directions, fig. 2A-5C col. 3 lines 8-20. At the time the invention was made; it would have been obvious to one of ordinary skill in the art to use the inorganic layer teaching of Yang to replace the inorganic layer 108 in Iwano's device, because such insulating material would have produced a low dielectric constant and low-cost inorganic dielectric material as taught by Yang in column 2 lines 38-40.

Regarding claims 4 and 10-11, Iwano discloses the semiconductor light emitting device according to any of claims to 3, wherein the mesa section includes a surface emission structure having an electrode 112, column 15 line 18, in a top portion and comprises a semiconductor layer 109, column 14 line 56, provided with an active layer 105 having a quantum well structure, column 14 line 53, constituted by a compound semiconductor, and a pad 112, fig. 1 (electrode 112 comprises a pad as shown in fig. 1), to come in contact with the electrode 112 is provided on the inorganic insulating film 108.

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Conclusion

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5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thao X. Le whose telephone number is (571) 272-1708. The examiner can normally be reached on M-F from 8:00 AM - 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael M. Fahmy can be reached on (571) 272 -1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Thao X. Le Patent Examiner

09 Jan. 2006